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Front Matter: Volume 10351

, "Front Matter: Volume 10351," Proc. SPIE 10351, UV and Higher Energy Photonics: From Materials to Applications 2017, 1035101 (11 September 2017); doi: 10.1117/12.2296951

SPIE.

Event: SPIE Nanoscience + Engineering, 2017, San Diego, California, United States

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UV and Higher Energy Photonics: From Materials to Applications 2017

**Gilles Léron del
Satoshi Kawata
Yong-Hoon Cho**
Editors

**6–7 August 2017
San Diego, California, United States**

Sponsored and Published by
SPIE

Volume 10351

Proceedings of SPIE 0277-786X, V. 10351

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

UV and Higher Energy Photonics: From Materials to Applications 2017, edited by
Gilles Léron del, Satoshi Kawata, Yong-Hoon Cho, Proc. of SPIE Vol. 10351, 1035101
© 2017 SPIE · CCC code: 0277-786X/17/\$18 · doi: 10.1117/12.2296951

Proc. of SPIE Vol. 10351 1035101-1

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Author(s), "Title of Paper," in *UV and Higher Energy Photonics: From Materials to Applications 2017*, edited by Gilles Lrondel, Satoshi Kawata, Yong-Hoon Cho, Proceedings of SPIE Vol. 10351 (SPIE, Bellingham, WA, 2017) Seven-digit Article CID Number.

ISSN: 0277-786X
ISSN: 1996-756X (electronic)

ISBN: 9781510611597
ISBN: 9781510611603 (electronic)

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA
Telephone +1 360 676 3290 (Pacific Time) · Fax +1 360 647 1445
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